



Nitric Oxide Microsensors for Engine Emissions, Environmental, and Human Health Monitoring Applications

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Outline

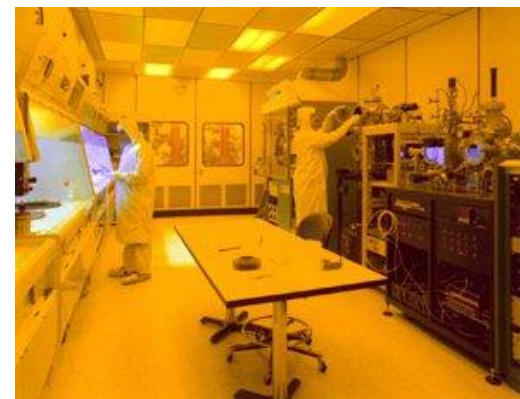
- **Background of Chemical Sensors at NASA GRC**
- **Development of Nitric Oxide (NO) Microsensors**
 - ◆ Harsh environment engine emission and environmental monitoring
 - ◆ Human health monitoring
- **Summary**



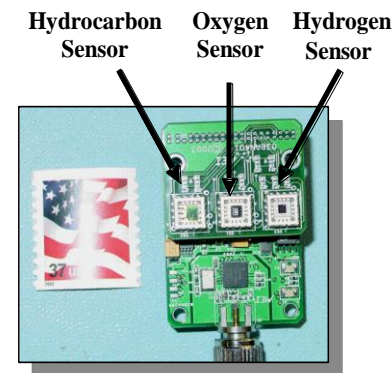
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Chemical Sensor Development at NASA GRC

- **Microsensors and platforms**
 - * H_2 , CH_4 , C_2H_4 , C_3H_6 , CO_2 , CO , O_2 , NO_x , and N_2H_4
 - * Orthogonal technology: different sensing mechanism
 - * Schottky diodes, resistors, and electrochemical cells
- **Applications**
 - * Propulsion system, fuel depot leak detection
 - * Low false alarm fire detection.
 - * Harsh environment engine emissions and environmental monitoring
 - * Human health monitoring and potential astronaut health evaluation
- **Approaches**
 - * Smart sensor system: sensor arrays, signal processing and conditioning components, power and telemetry
 - * “Lick and Stick” for full-field view of environment
 - * Nanotechnology and batch microfabrication
 - * Small size, low weight, cost, and power consumption



NASA GRC Sensors and Electronics
Branch cleanroom



Example of smart
sensor system

Development of Nitric Oxide Microsensors

- **Harsh environment engine emission and environmental monitoring**

- * Detection limit required: ppm level

- **Human health monitoring application**

- * Detection limit required: 10 ppb; e.g. Asthma patient.

- **Parallel Approaches**

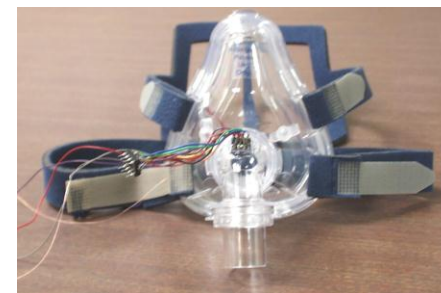
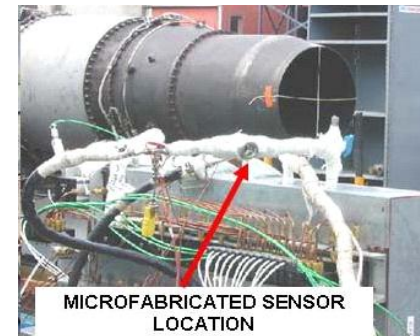
- * Electrochemical cells

- * SiC based sensors

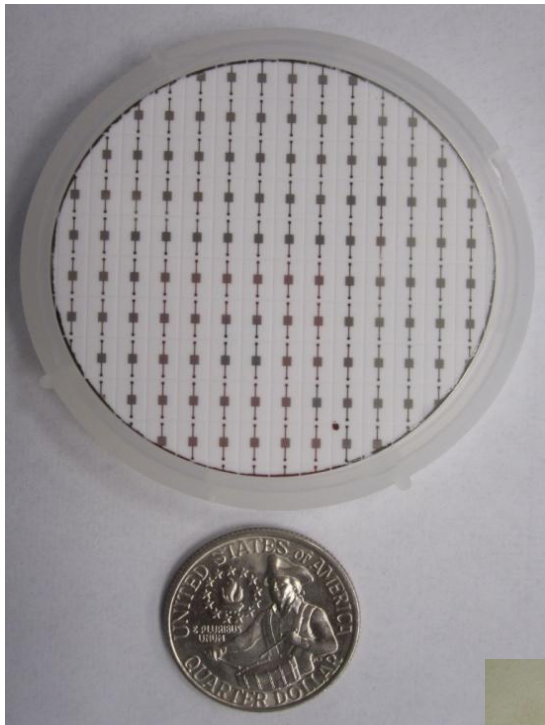
- * **Resistor based sensors**

- ◆ N-type semiconductor Indium Tin Oxides (ITO): sensitive materials for reducing gases

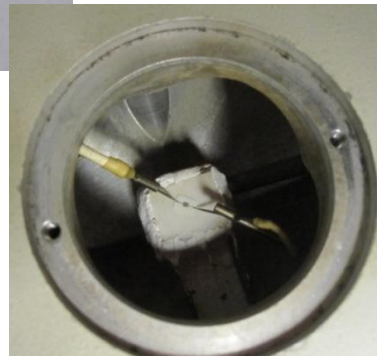
- ◆ Two types of films investigated : sputter deposition and polymer precursor



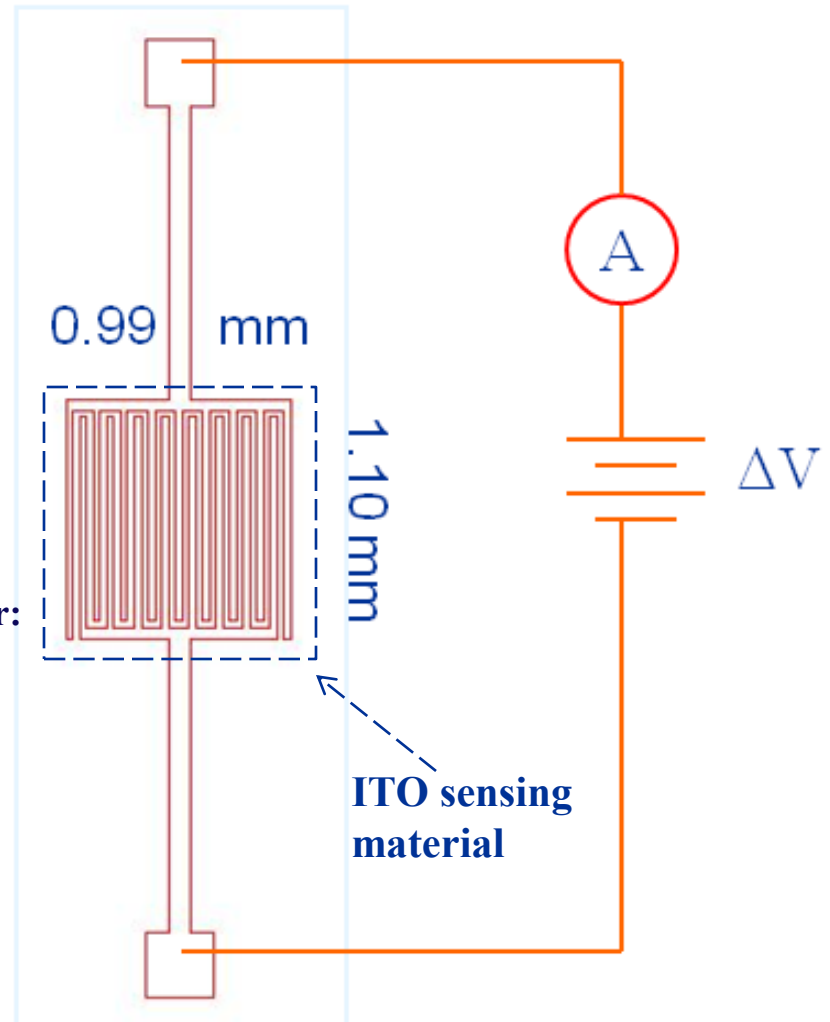
Pt interdigitated electrodes fabricated on a 2-inch alumina wafer



Gas testing chamber:
Probe contact



Electrode structure and schematic of gas testing setup





Two Approaches to Deposit ITO Sensing Materials

- **Sputter Deposition**

- * ITO Sputter Target: 90% In₂O₃ and 10% SnO₂ (by weight)

- * 1200 Å ITO

- **ITO organic precursors**

- * Mixture of 2-ethylhexenoic acid modified indium isopropoxide and tin isopropoxide

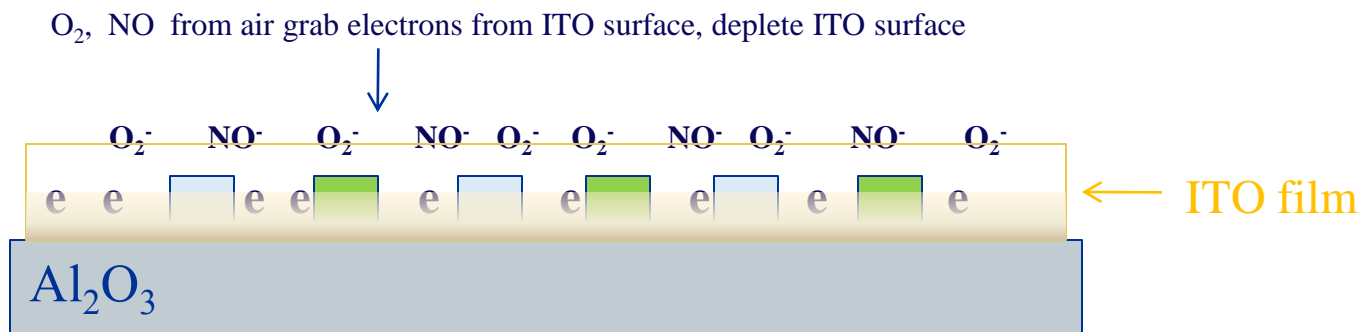
- * Drop deposit on the interdigitated electrode, heat treat



- * Thickness in the micro range

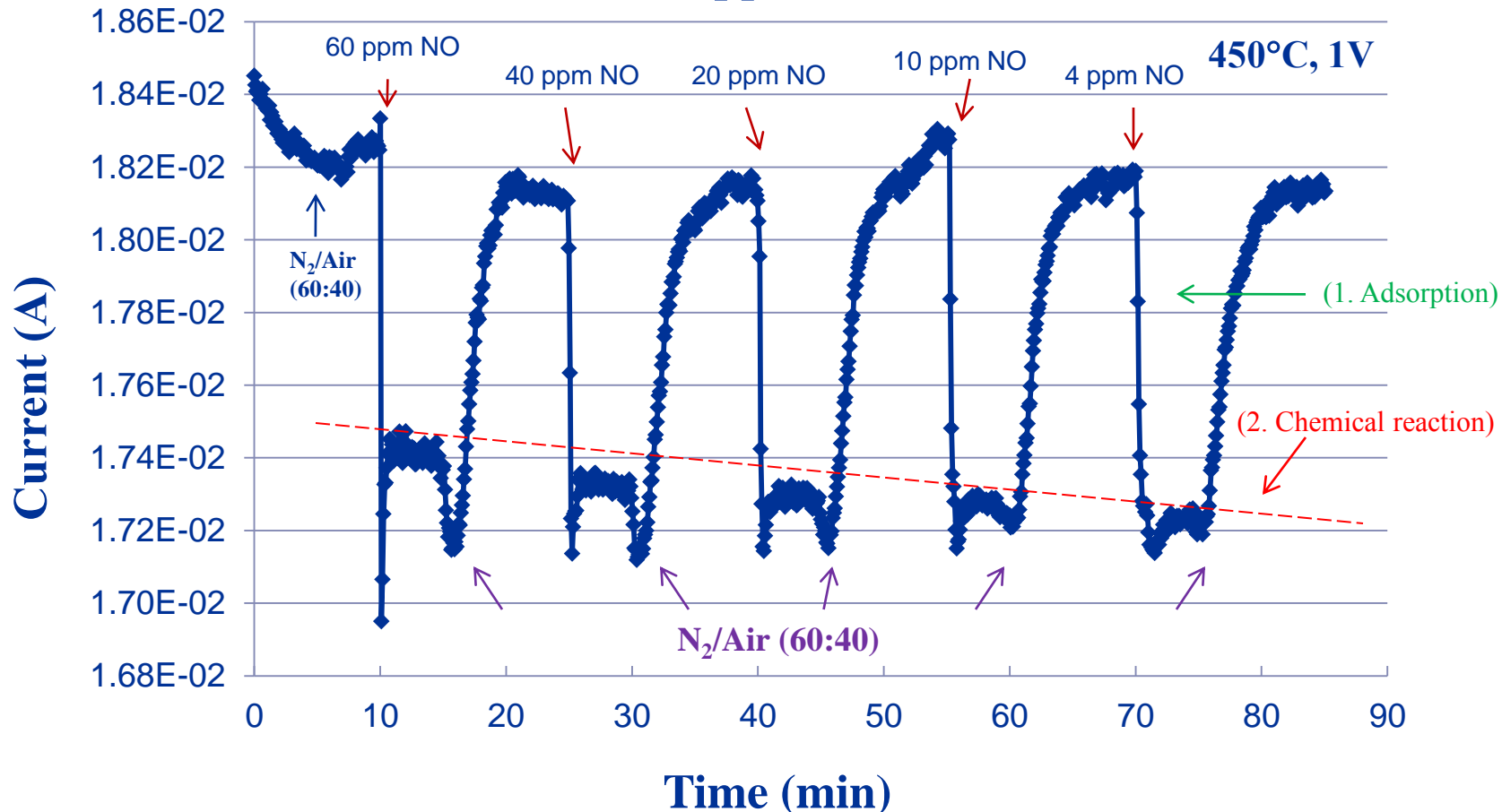
Sensing Mechanism

- **Sputter ITO Thin film: at 450°C, 1V, NO sensing involves two processes:**
 - * Low concentration (ppb to low ppm): adsorption
 - * High concentration (ppm): adsorption and NO oxidation reaction:



- ◆ Adsorption: O₂ and NO adsorbed on the ITO surface, deplete surface electrons, increase film resistance: $O_2 + e \rightarrow O_2^-$; $NO + e \rightarrow NO^-$
- ◆ Reaction: NO react with O₂⁻, release electrons back to ITO, decrease resistance: $NO + O_2^- \rightarrow NO_x (NO_2 + N_2O_3 + N_2O_5 \dots) + ne$

Sputtered ITO Microsensor Response to Nitric Oxide Gas (ppm)



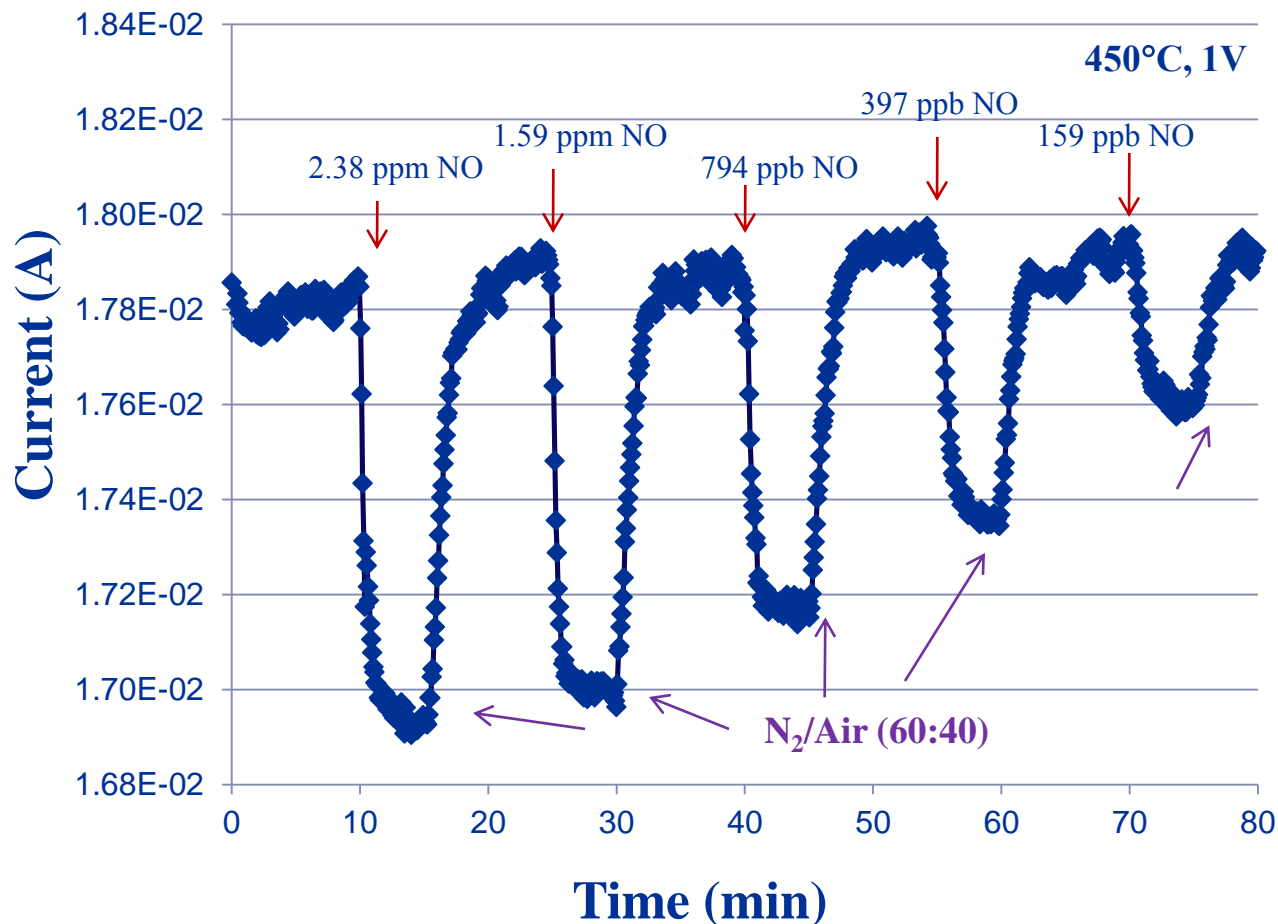
Note: 1200 Å ITO thin film deposited in sputter system.

NO concentration: 100 ppm NO in N_2 gas. The NO was diluted with N_2 and Air to match base gas

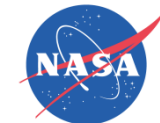
N_2 and Air ratio (60 : 40). Total flow is 2500 sccm.



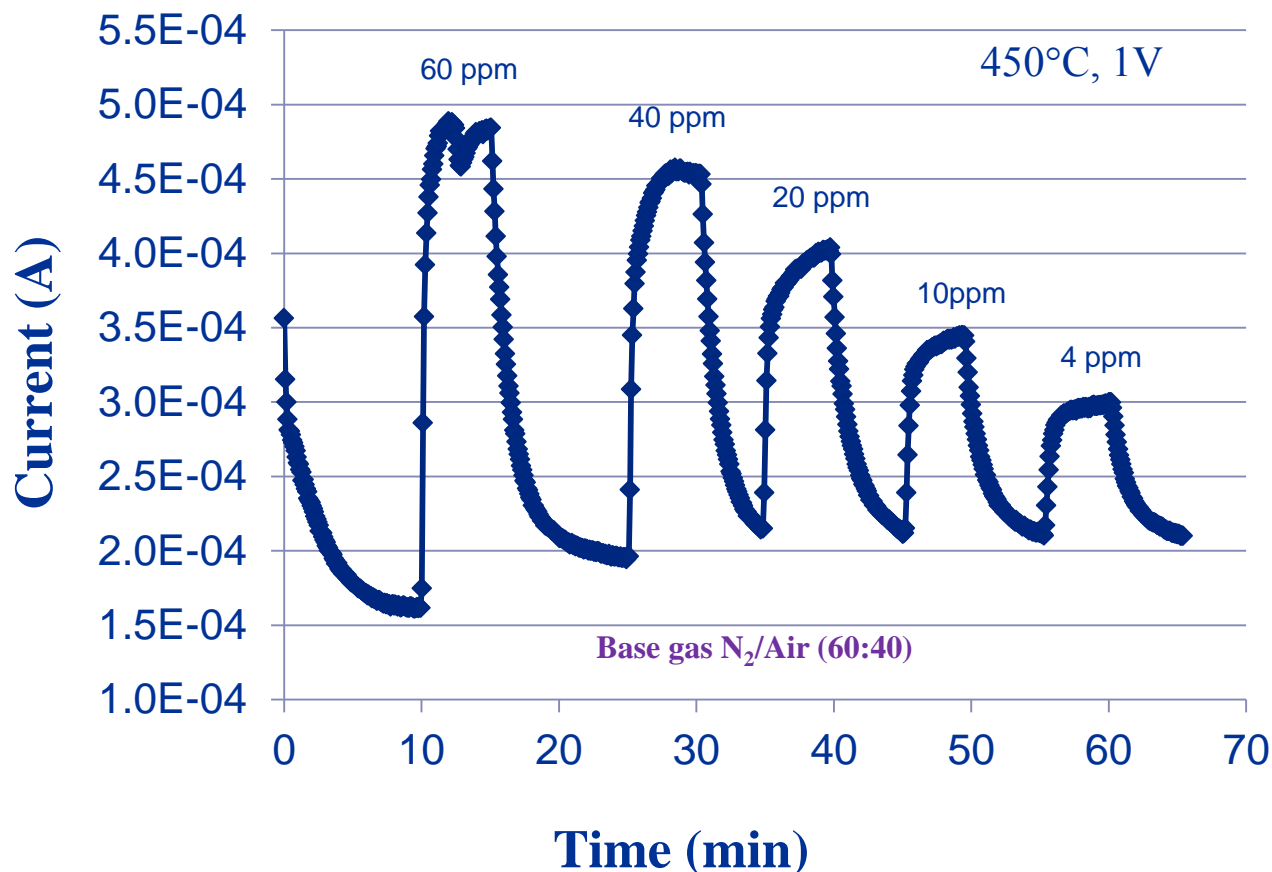
Sputter Deposited Nitric Oxide Microsensor Response to Nitric Oxide Gas (ppb-ppm)



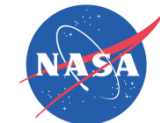
Note: Original NO concentration: 3.97 ppm NO in N₂ gas. The NO was diluted with N₂ and Air to match base gas: N₂ and Air ratio (60 : 40). Total flow is 2500 sccm.



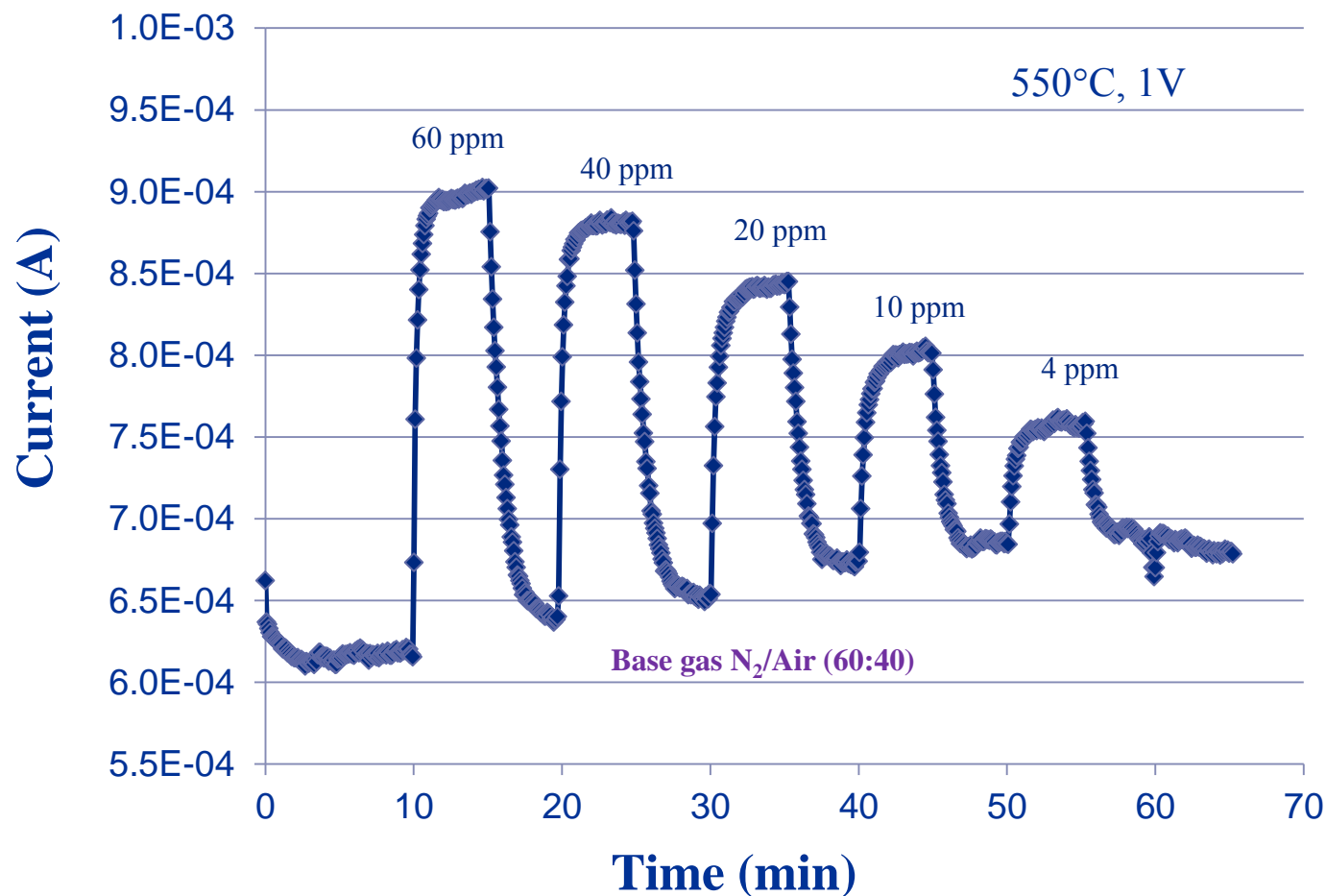
Nitric Oxide Microsensor (ITO from polymer precursor) Response to Nitric Oxide Gas (ppm)



Note: ITO sensing material from ITO polymer precursor, heat-treated at 550°C for 2 hr
NO concentration: 100 ppm NO in N₂ gas. The NO was diluted with N₂ and Air to match baseline N₂ and Air ratio (60 : 40). Total flow is 2500 sccm.



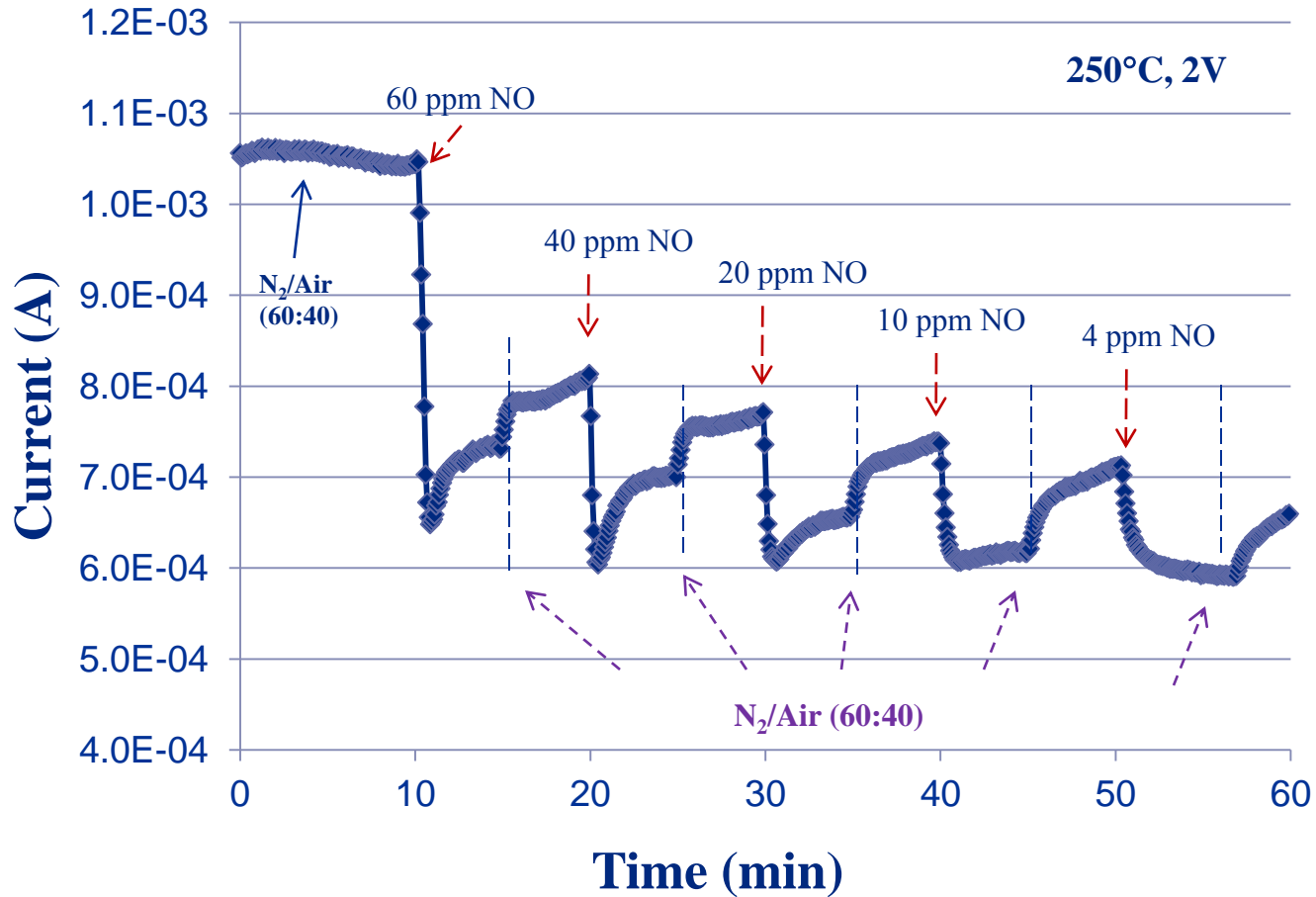
Nitric Oxide Microsensor (ITO from polymer precursor) Response to Nitric Oxide Gas (ppm)



Note: ITO sensing material from ITO polymer precursor, heat-treated at 550°C for 2 hr
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Nitric Oxide Microsensor (ITO from polymer precursor) Response to Nitric Oxide Gas (ppm)



Note: ITO sensing material from ITO polymer precursor, heat-treated at 550°C for 2 hr
NO concentration: 100 ppm NO in N_2 gas. The NO was diluted with N_2 and Air to match base gas N_2 and Air ratio (60 : 40). Total flow is 2500 scfm.



Sensing Mechanism

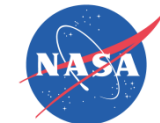
(with ITO from organic precursor)

- **High temperatures, 450°C to 550°C, involve one process:**
NO oxidation reaction: $\text{NO} + \text{O}_2^- \rightarrow \text{NO}_x (\text{NO}_2 + \text{N}_2\text{O}_3 + \text{N}_2\text{O}_5 \dots) + ne$
- **Low temperature: 250°C, 2V, involves two processes (like sputtered film in ppb level NO gases):**
NO adsorption and NO oxidation reactions
- ◆ **Next: Film surface morphology analysis to understand different NO sensing behavior**



Summary

- **Resistor based nitric oxide microsensor being developed for aerospace applications: engine emission and health monitoring**
- **Two approaches used for the ITO sensing materials exploration. Preliminary data showed NO detection from ppm to ppb achieved. Improvement in detection limit needed**
- **Two sensing mechanisms involved: adsorption and chemical reaction. ITO films from different processes have different behaviors. More investigation needed to develop practical NO sensors**
- **Extensive testing and surface morphology studies to be conducted**
- **Provide potential simple and sensitive NO sensors: low cost, small size, batch fabrication, high yield, and easy use**
- **Provide quick information for selecting NO sensing materials for nano-structure NO sensor development.**



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Thank You!

Please visit:

<http://www.grc.nasa.gov/WWW/sensors/>